VD.

	Application No.	Applicant(s)	
Notice of Allowability	10/765,046	INOUE ET AL.	
	Examiner	Art Unit	
	Helene Klemanski	1755	
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.			
1. This communication is responsive to <u>amendment filed February 3, 2005</u> .			
2. The allowed claim(s) is/are <u>12-14 and 17-19</u> .			
3. The drawings filed on 28 January 2004 and 03 February 2005 are accepted by the Examiner.			
 4. Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some* c) None of the: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)). * Certified copies not received: 			
Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application. THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.			
5. A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.			
6. CORRECTED DRAWINGS (as "replacement sheets") must be submitted.			
(a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review (PTO-948) attached			
1) hereto or 2) to Paper No./Mail Date			
(b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).			
7. DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.			
Attachment(s) 1. ☐ Notice of References Cited (PTO-892) 2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Summary	5. Notice of Informal Patent Application (PTO-152) 6. Interview Summary (PTO-413), Paper No./Mail Date 7. Examiner's Amendment/Comment 8. Examiner's Statement of Reasons for Allowance 9. Other HELENE/KLEMANSKI PRIMARY EXAMINER CROUP 1900	
 Information Disclosure Statements (PTO-1449 or PTO/SB/08). Paper No./Mail Date <u>2/3/05</u> Examiner's Comment Regarding Requirement for Deposit of Biological Material 	7. ☐ Examiner's Amenda8. ☐ Examiner's Stateme		

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Information Disclosure Statement

1. The AO reference that the examiner did not initial in the previous IDS filed January 28, 2004 has now been considered and an initialed copy of the IDS filed February 3, 2005 is being sent to applicants as an attachment to this Office Action.

REASONS FOR ALLOWANCE

2. The following is an examiner's statement of reasons for allowance: This application teaches a method for manufacturing an electronic device wherein the method comprises electroless plating an electronic device having an embedded interconnect structure with an electroless Ni-B plating liquid. The liquid forms a protective layer of a Ni-B alloy film having a thickness of 10 to 100 nm on the surface of the interconnect. The electroless Ni-B plating liquid comprises nickel ions, a complexing agent, a reducing agent and ammonium ions. Applicants have overcome the 102(e) rejection over Inoue et al. (US 2003/0019426) by the perfecting their priority, which gives applicants a priority date of November 28, 2000. The closest prior art of record is U.S. Patent No. 5,269,838, issued to Inoue et al., which teaches a coating film having a thickness of 5-200 μm and fails to teach or fairly suggest a coating film having a thickness of 10 to 100nm (i.e. 0.01-0.1μm) as claimed by applicants. Accordingly, this application is allowable.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably Application/Control Number: 10/765,046

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Helene Klemanski whose telephone number is (571) 272-1370. The examiner can normally be reached on Monday-Friday 5:30-2:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Jerry Lorengo can be reached on (571) 272-1233. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR.

Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

Helene Klemanski Primary Examiner Page 3

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May 2, 2005